An Example Abstract for the International Conference on Electron, Ion, and Photon Beam Technology and Nanofabrication

A. Einstein, C.A de Coulomb

*Institute for Nanofabrication, University College, Cambridge, MA 02139*

*einstein@university.edu*

R. Fineman

*HAL Laboratory of Quantum Studies, 137 Coupling Way, Pasadena, CA 91109*

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*Figure 1: The Debutantes' Ball:* At the debutantes' ball, young nano-women gather in their finery at the edge of the stage to weep because none of the nano-boys will dance with them. The micrograph shows an array of 50 nm wide posts with a periodicity of 100 nm. The posts consist of PMMA on top of an antireflection coating. The substrate consists of a 250 nm thick layer of silicon nitride on silicon. Winner of the 1995 “Most Bizarre Micrograph” prize. Submitted by Tim Savas, Massachusetts Institute of Technology.

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